

Electronic Supplementary Information

Achieving Current Rectification Ratio $\geq 10^5$ across Thin Film of Coordination Polymer

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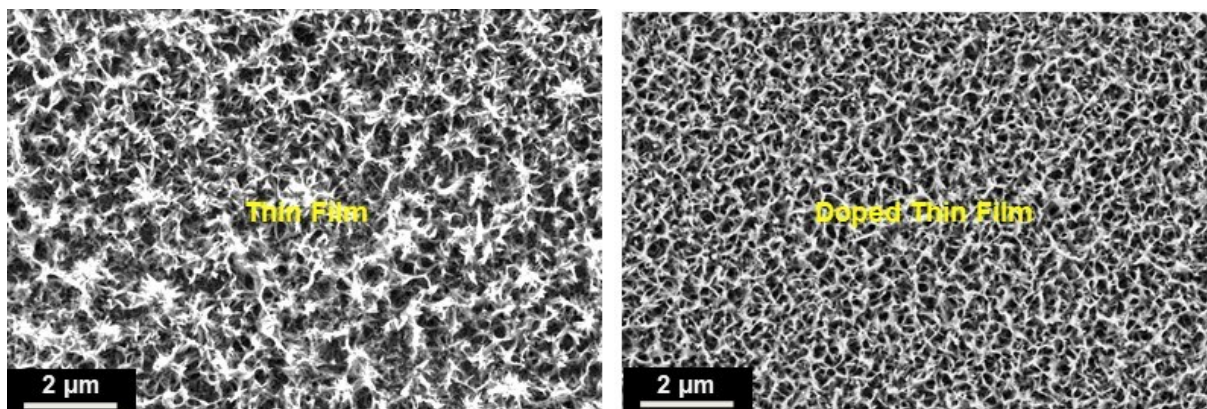


Figure S1. Zoomed-in FE-SEM images on pristine Cu-BTEC (left) and doped Cu-BTEC (right) thin films.

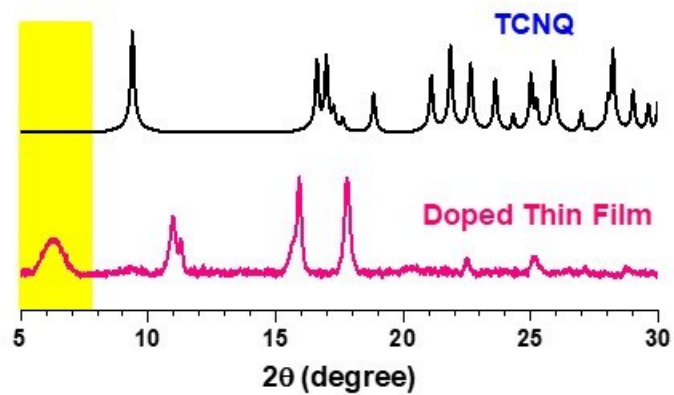


Figure S2. PXRD patterns of bulk TCNQ (black) and TCNQ doped Cu-BTEC thin film (pink).

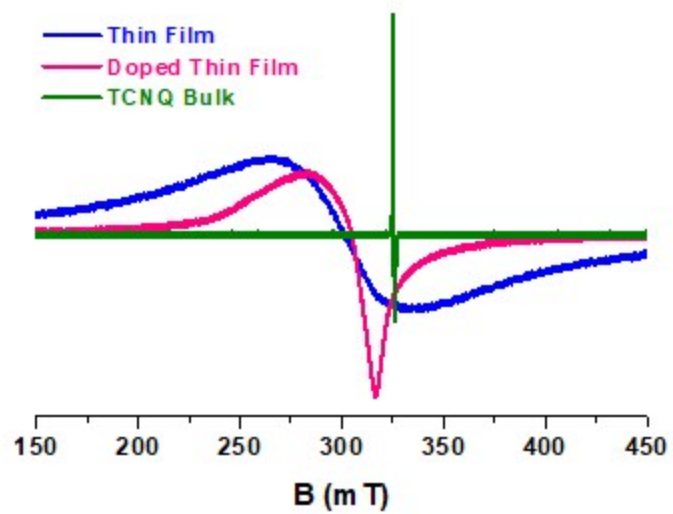


Figure S3. EPR spectra recorded on pristine Cu-BTEC thin film (blue), TCNQ doped Cu-BTEC thin film (pink) and TCNQ bulk powder (green).

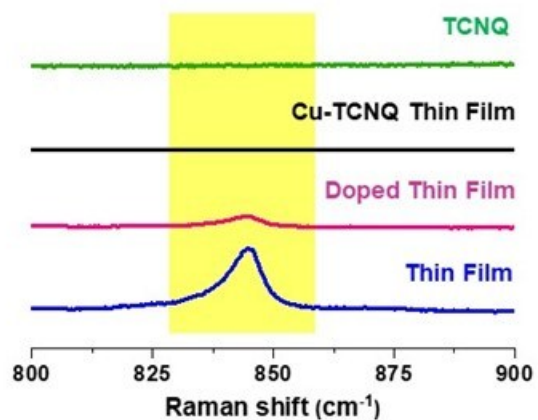


Figure S4. Raman spectra of pristine and doped Cu-BTEC thin films and pristine Cu-TCNQ thin film. Band characteristic of C-H out-of-plane bending mode at $\sim 845\text{ cm}^{-1}$ (highlighted in yellow) in the doped Cu-BTEC thin film is suppressed in comparison to pristine Cu-BTEC thin film which was absent in pristine Cu-TCNQ thin film.

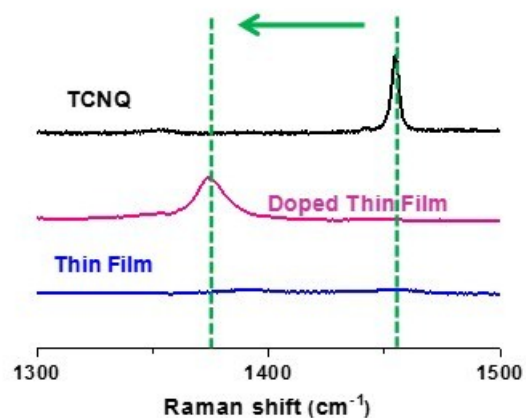


Figure S5. Raman spectra of pristine (blue) and doped Cu-BTEC (pink) thin films and of pure TCNQ (black). A significant red-shift of the band characteristic of C=C wing stretching mode of TCNQ from $\sim 1455\text{ cm}^{-1}$ to $\sim 1374\text{ cm}^{-1}$ was observed in doped thin film (pink).

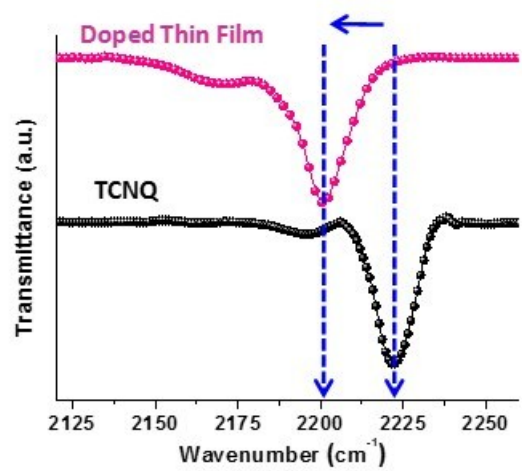


Figure S6. FTIR spectrum of pure TCNQ (black) and IRRAS spectrum of doped Cu-BTEC thin film.

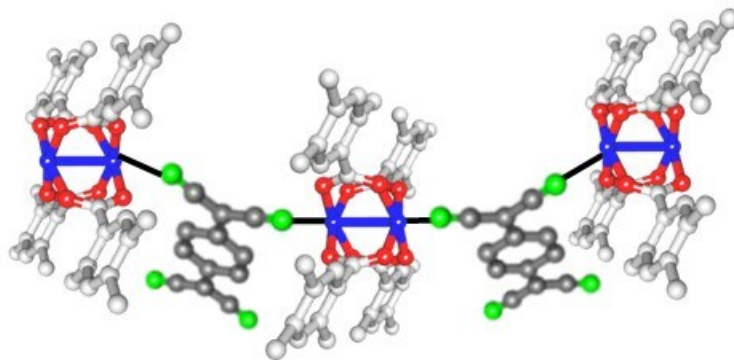


Figure S7. Schematic of bonding motif of TCNQ molecules to Cu-BTEC units.

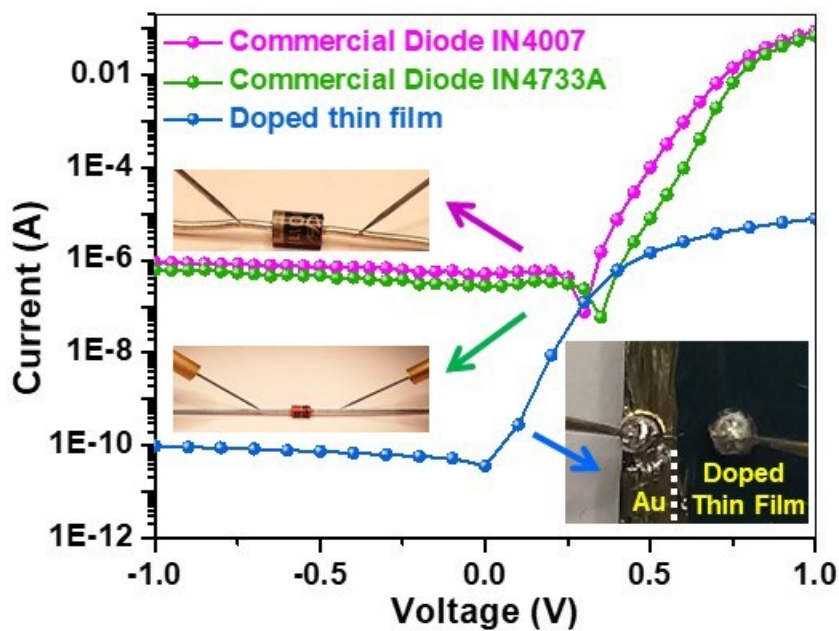
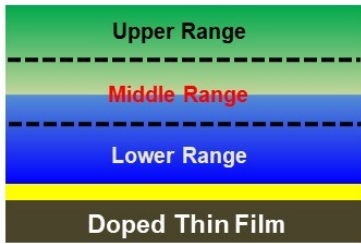


Figure S8. Direct comparison of I-V characteristics of the doped Cu-BTEC thin film (blue) with commercial Si rectifier diodes (1N4007, magenta and 1N4733A, green; and respective optical images are shown). An optical image of TCNQ doped Cu-BTEC thin film device showing the cross-plane I-V measurement after scratching out sample to expose the Au substrate.



Upper Range (Nitrogen)	Middle Range (Nitrogen)	Lower Range (Nitrogen)
23.49 (a)	14.89 (d)	3.87 (g)
26.62 (b)	15.62 (e)	1.85 (h)
18.95 (c)	11.50 (f)	3.65 (i)

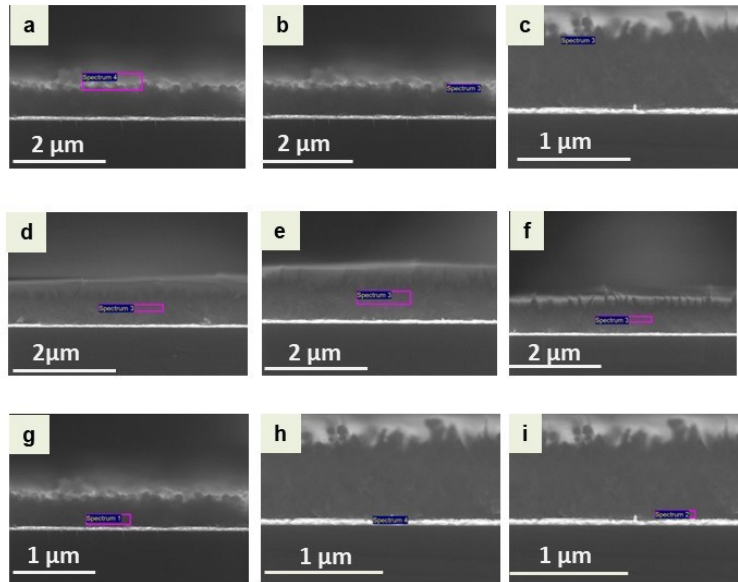


Figure S9. Cross-sectional EDXS analysis of the doped Cu-BTEC thin film in three different ranges (upper, middle and lower) with corresponding FE-SEM images.

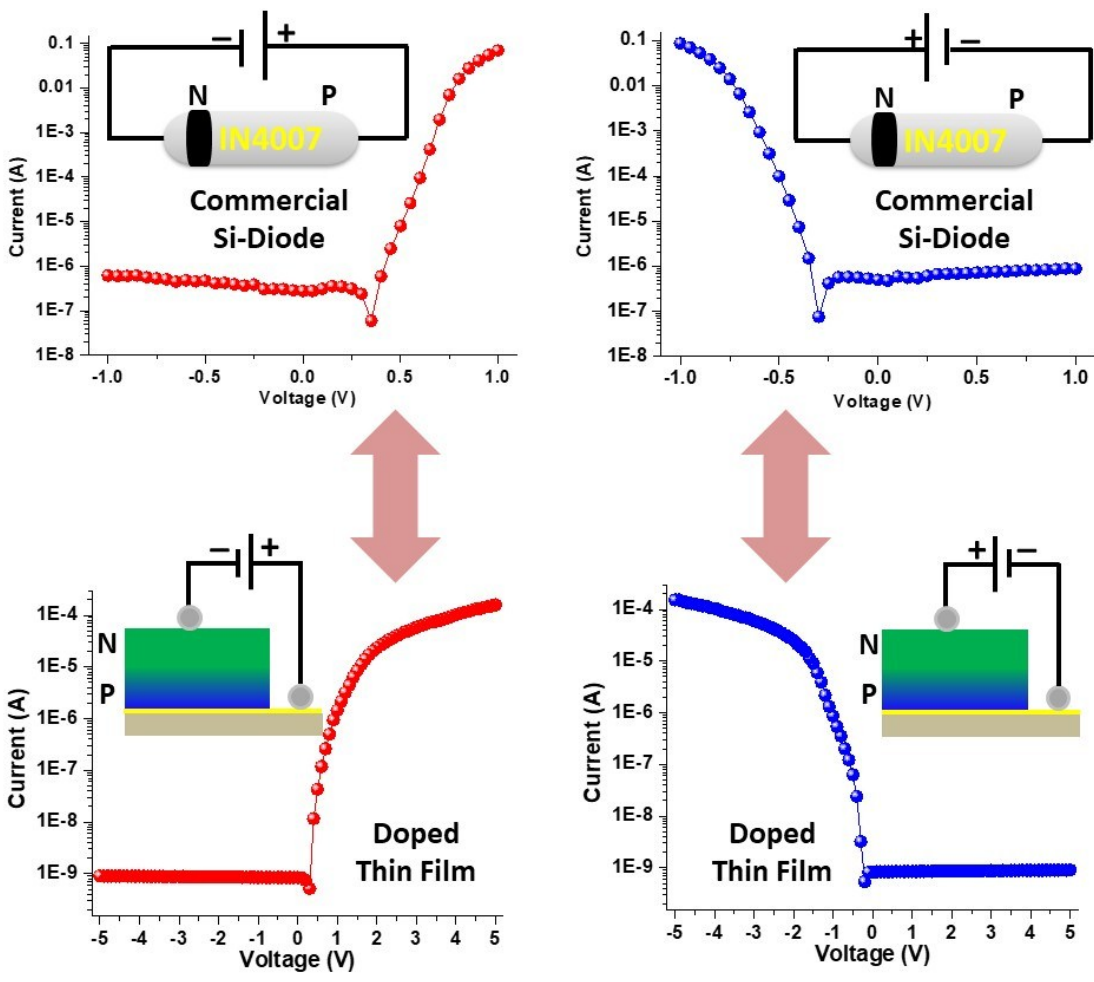


Figure S10. I-V characteristics on commercial IN4007 Si diode in forward bias (top left, red circles) and reverse bias (top right, blue circles). I-V characteristics of our TCNQ doped Cu-BTEC thin film upon changing the direction of current flow from SMU-2 to SMU-1 (bottom left, red circles, forward bias) and SMU-1 to SMU-2 (bottom right, blue circles, reverse bias). Identities of p and n sides are marked for clarity.

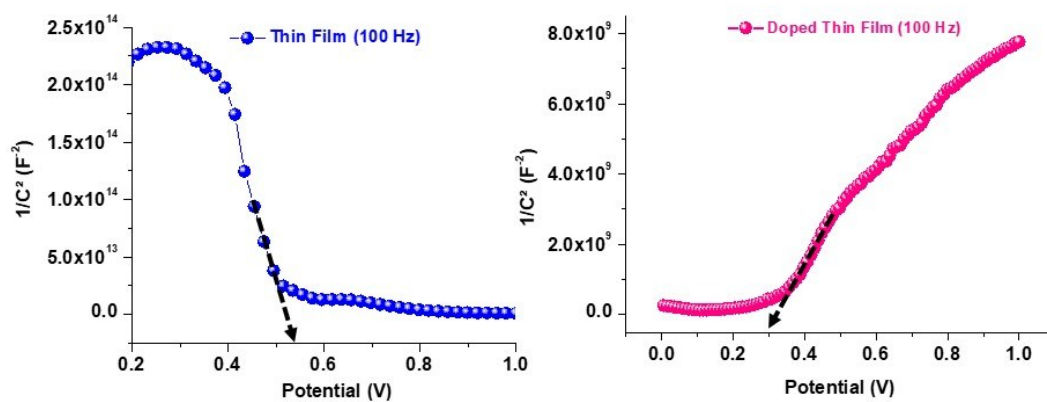


Figure S11: Mott-Schottky plots ($1/C^2$ versus V where C is capacitance and V is voltage) recorded on pristine (left panel) and doped (right panel) Cu-BTEC thin films at 100 Hz. Respective slopes are indicated by black arrows.

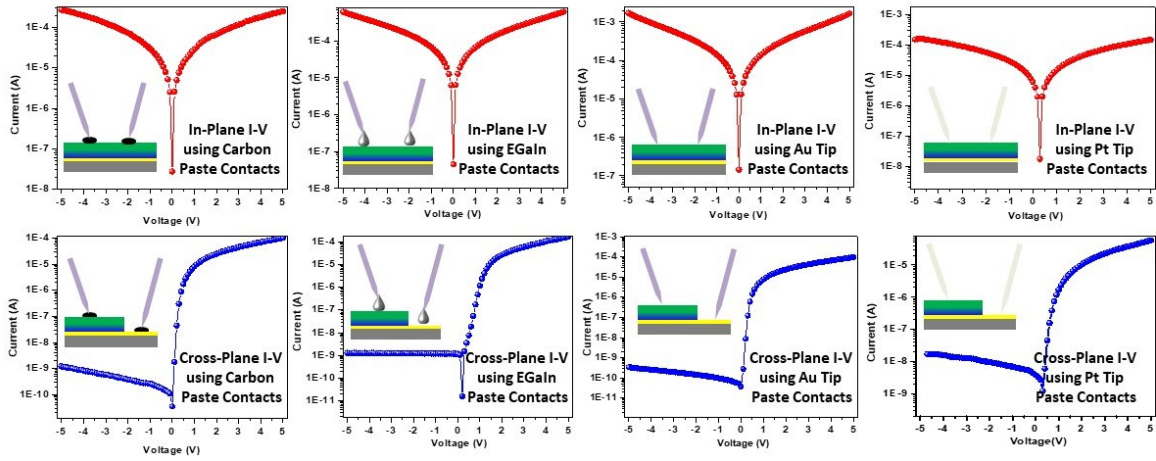


Figure S12. I-V characteristics of the doped Cu-BTEC thin film both in-plane (top panels) and cross-plane (bottom panels) modes recorded using various contacts (C-paste, EGaIn, direct Au-tip and direct Pt-tip).

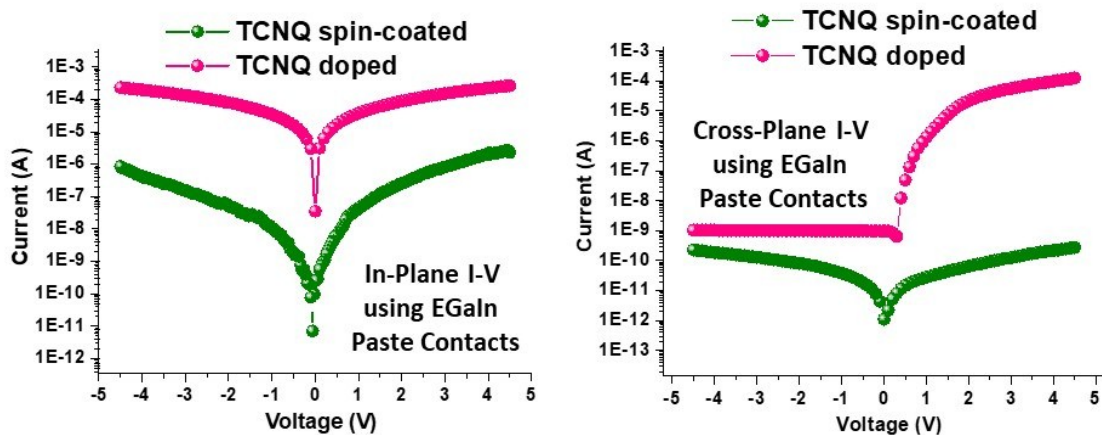


Figure S13. I-V characteristics recorded on the TCNQ spin-coated Cu-BTEC thin film both in-plane (left) and cross-plane (right) modes using EGaln contacts (green circles). As reference, data on TCNQ doped Cu-BTEC thin film are provided (pink circles) and the marked difference is the current rectification.

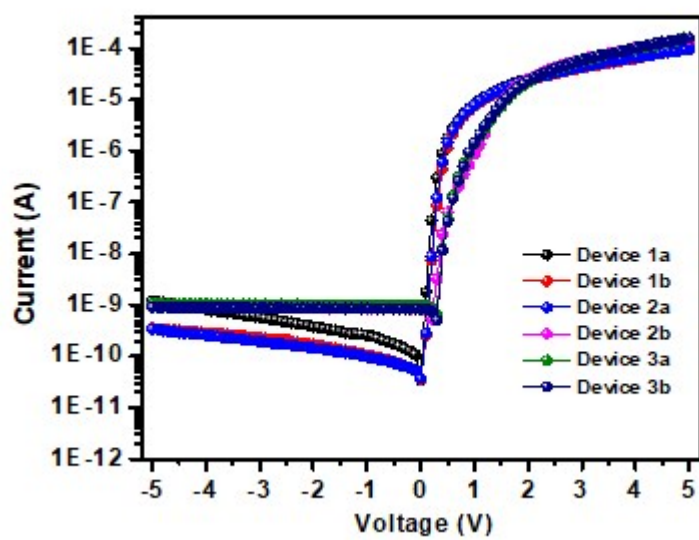


Figure S14. Cross-plane I-V characteristics on 3 different batches of TCNQ doped Cu-BTEC thin film and on two different points on the sample surface.

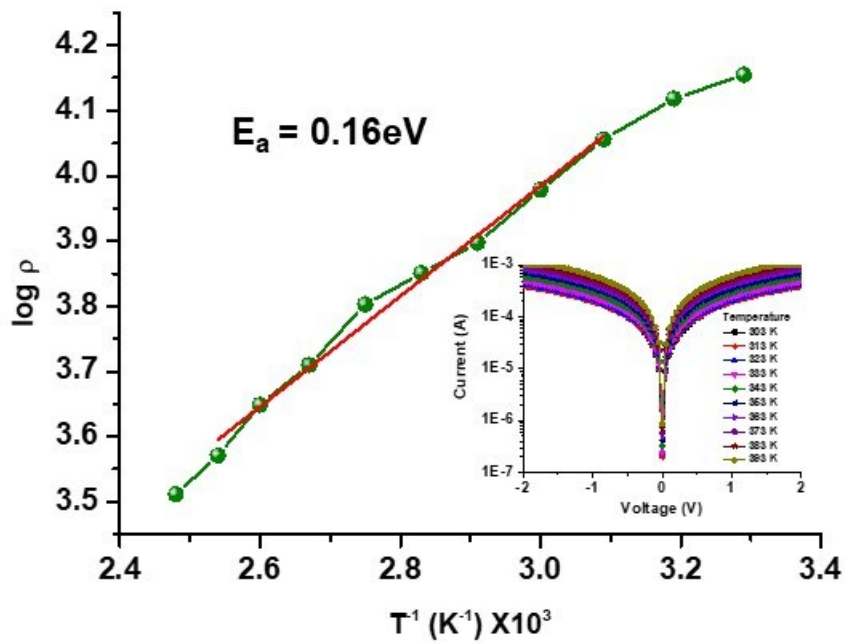


Figure S15. Estimation of activation energy (E_a) from Arrhenius plot extracted from the temperature-dependent conductance study.

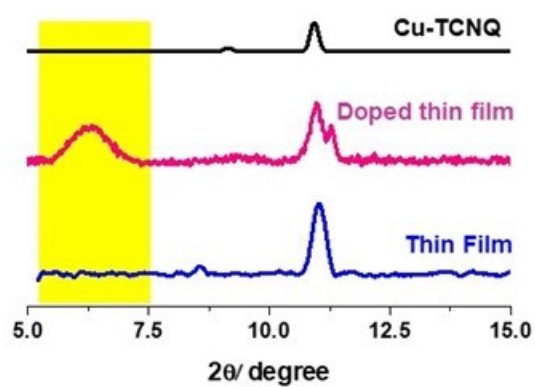


Figure S16. Out-of-plane XRD pattern of pristine (blue) and doped (pink) Cu-BTEC thin films and of pristine Cu-TCNQ thin film. The peak at $2\theta \sim 5.8^\circ$ characteristic of pore-filling phenomenon in Cu-BTEC system is not a characteristic of pristine Cu-TCNQ thin film (highlighted in yellow).

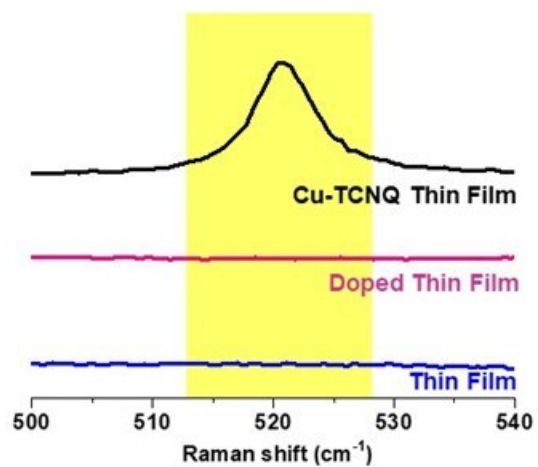


Figure S17. Raman spectra of pristine (blue) and doped (pink) Cu-BTEC thin films and of pristine Cu-TCNQ thin film (black). Band at 520 cm⁻¹ is due to Cu---Cu interaction mode appeared in pristine Cu-TCNQ thin film was consistently absent in both pristine and doped Cu-BTEC thin films (highlighted in yellow).

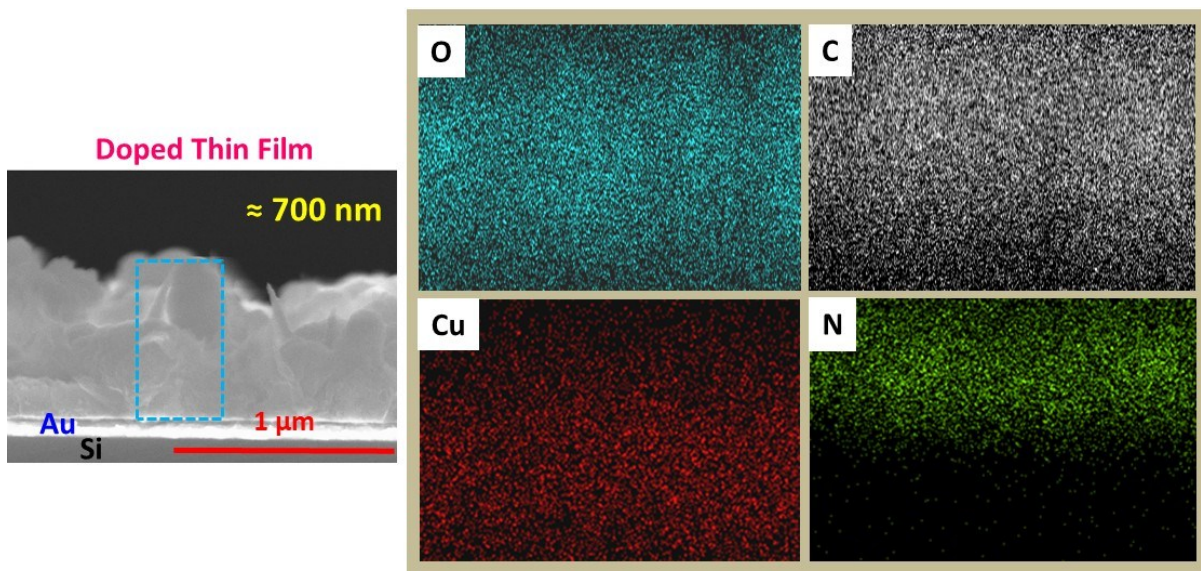


Figure S18. Cross-sectional elemental mapping of O, C, Cu and N on the doped Cu-BTEC thin film by EDXS analysis showing the absence of TCNQ in lower region near the Au substrate.

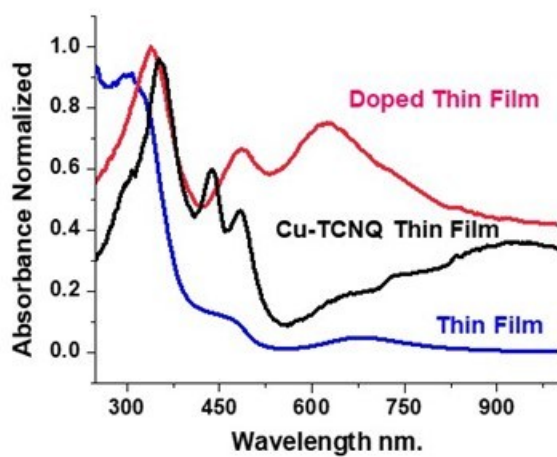


Figure S19. Distinctive solid-state UV-vis spectra of pristine (blue) and doped (pink) Cu-BTEC thin films and of pristine Cu-TCNQ thin film (black).

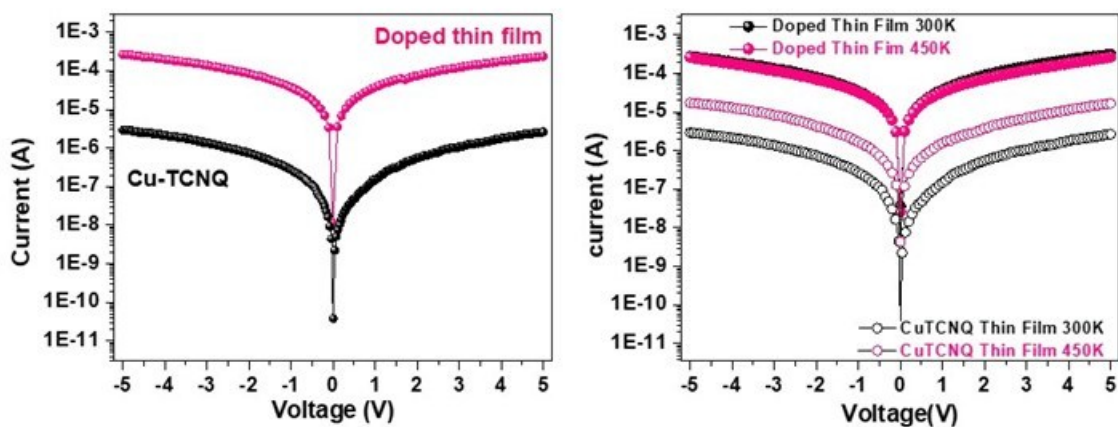


Figure S20. In-plane I–V characteristics of doped (pink) Cu-BTEC and pristine Cu-TCNQ (black) thin films (left panel). Variable-temperature in-plane I–V characteristics of doped Cu-BTEC thin film recorded at 300 K (black filled circle) and at 450 K (pink filled circle); and of pristine Cu-TCNQ thin film recorded at 300 K (black open circle) and at 450 K (pink open circle) (right panel).